

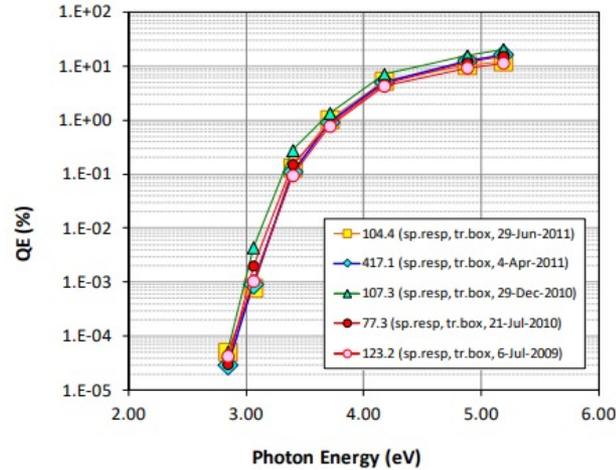
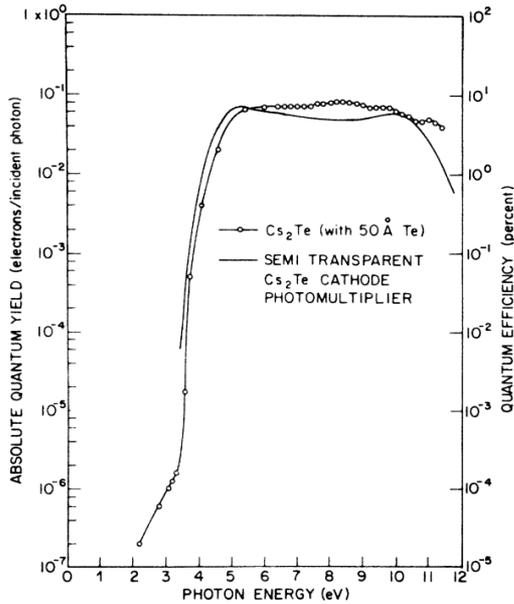
# Monte Carlo Simulation Study of $\text{Cs}_2\text{Te}$

## PITZ (DESY)

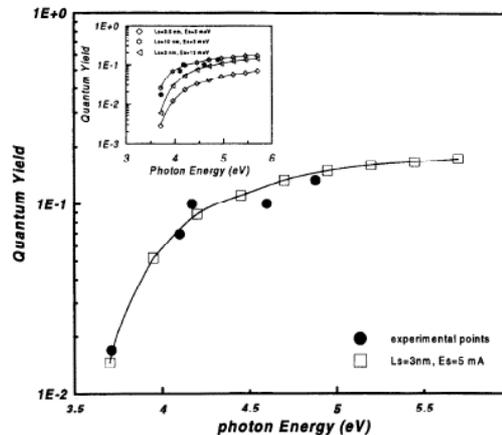
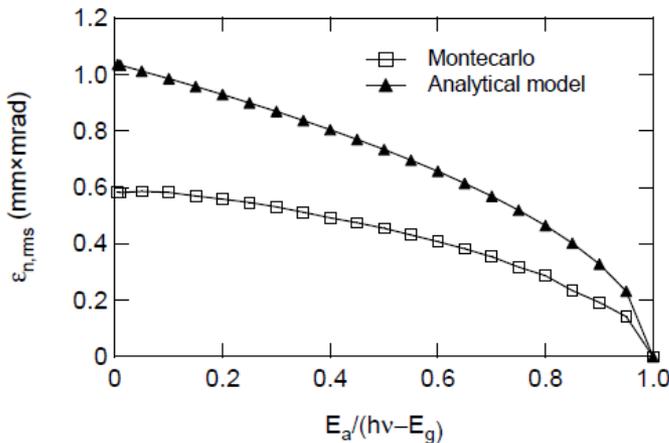
Gowri Adhikari

- Introduction
- Density Functional Theory (DFT)
  - Band structure
  - Effective mass
- Three-step model
- Absorption profile
- Initial parameters for the emission
- Phonon scattering
- Transmission probability
- Quantum efficiency
- Thermal emittance
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# Introduction

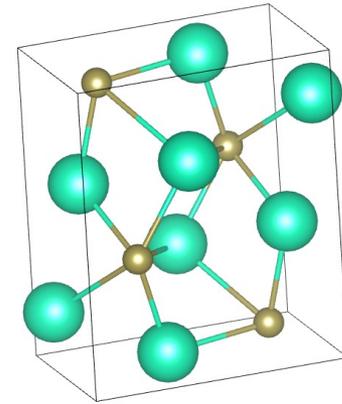
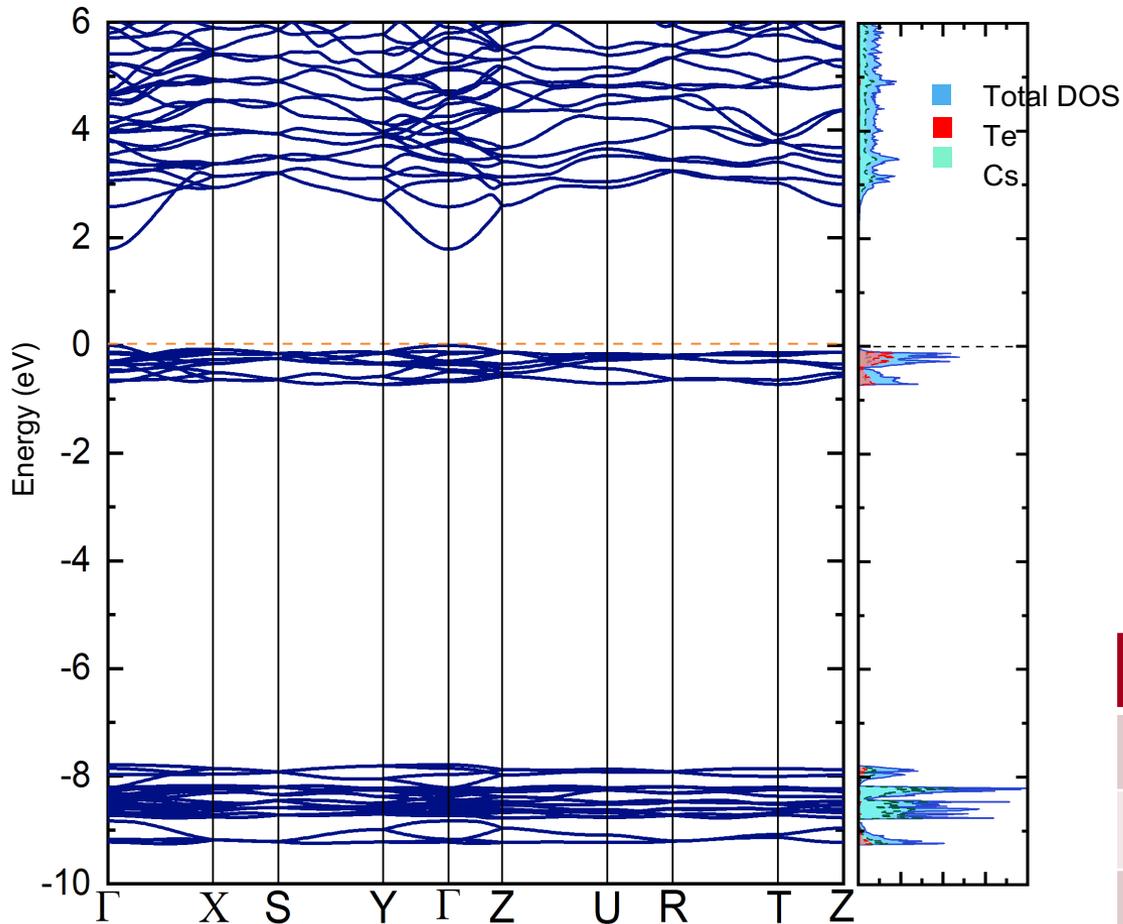


Several experiments have been devoted to characterizing  $\text{Cs}_2\text{Te}$  photocathodes in terms of quantum yield and thermal emittance.



Monte Carlo simulation was applied to simulate the quantum yield dependence on photon energy in  $\text{Cs}_2\text{Te}$  and the transverse emittance dependence on the electron affinity.

# Band structure and Density of states – Cs<sub>2</sub>Te



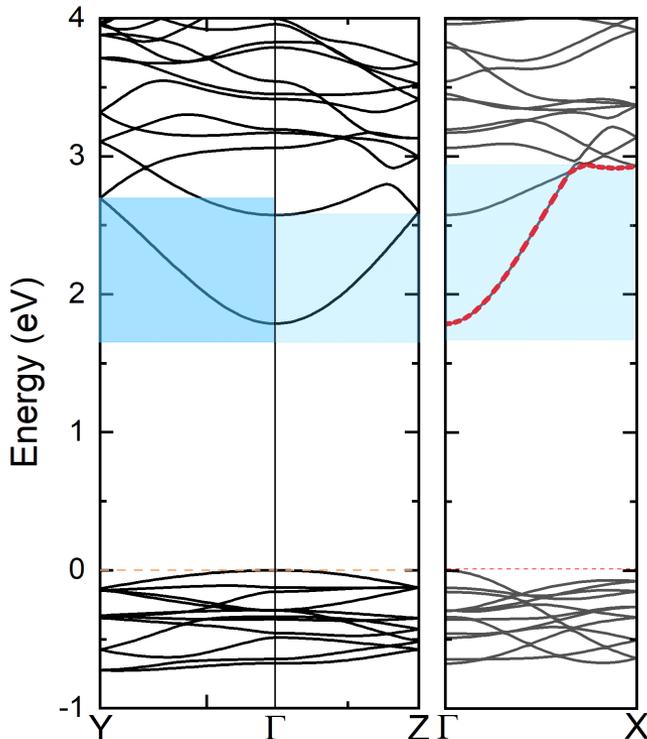
Orthorhombic crystal structure  
Space group *pnma* (62)

|       | DFT    | Ref (6) | EXP (5) |
|-------|--------|---------|---------|
| a (Å) | 5.844  | 5.845   | 5.871   |
| b (Å) | 9.415  | 9.542   | 9.109   |
| c (Å) | 11.663 | 11.591  | 11.474  |

# Band structure and Density of states – Cs<sub>2</sub>Te

- A parabolic fit was used to calculate the effective mass using the curvature of the fit.
- The effective mass at the Fermi energy can calculate using

$$m^* = \hbar^2 \left( \frac{d^2 E}{dk^2} \Big|_{k=k_f} \right)^{-1}$$



| Direction    | ΓX direction |
|--------------|--------------|
| ΓX direction | 0.27 $m_0$   |
| YΓ direction | 0.25 $m_0$   |
| ΓZ direction | 0.27 $m_0$   |

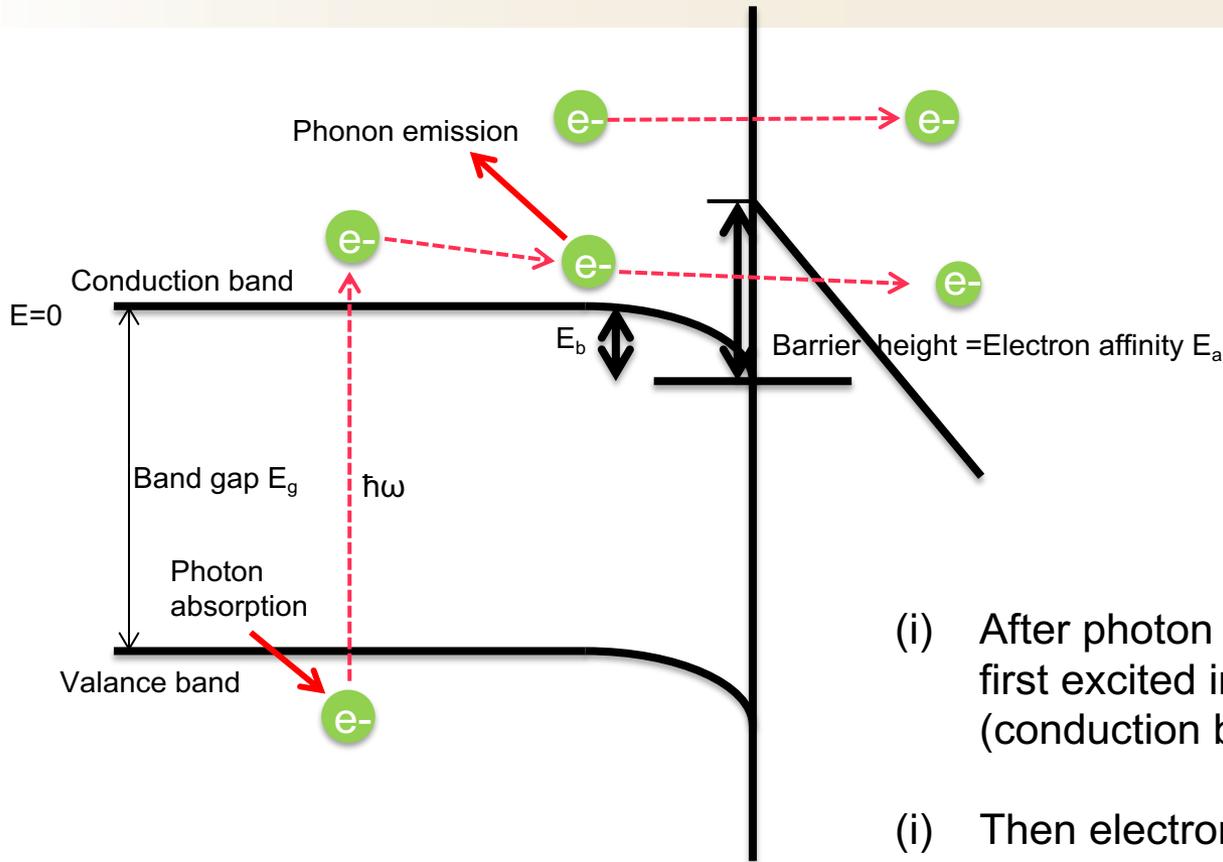
- Electron effective mass roughly estimated using

$$m^* = \frac{E_g m_0}{R_\infty},$$

where  $m_0$  - electron effective mass and  $R_\infty$  - Rydberg Constant 13.606 eV  $E_g$  - band gap.

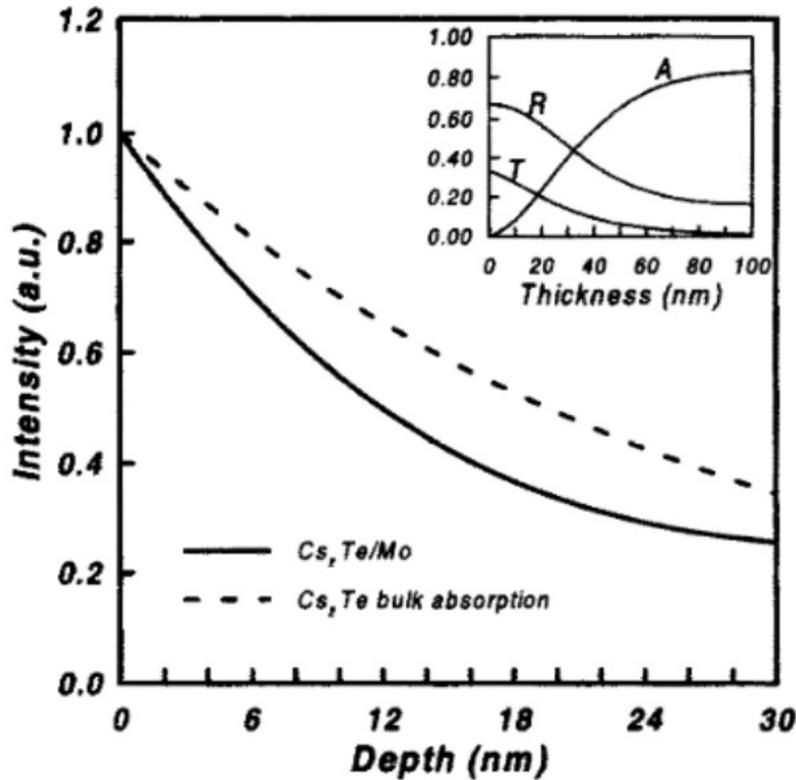
- According to the above equation  $m^*$  is 0.2425 and this value is very close to the DFT calculated effective mass.

# Three-step model



- (i) After photon absorption, the electrons are first excited into a higher energy state (conduction band).
- (i) Then electrons transfer to the surface with or without scattering.
- (i) Finally, the electrons escape into the vacuum.

# Absorption profile – Cs<sub>2</sub>Te



Absorption profile curve for Cs<sub>2</sub>Te bulk and Cs<sub>2</sub>Te/Mo interface with a Cs<sub>2</sub>Te thickness of 30nm. Inset- reports the reflectance (R), transmission (T), and absorption (A) of Cs<sub>2</sub>Te/Mo as function of Cs thickness.

- The absorbed laser energy decays exponentially along the cathode's thickness.

$$F(s) = F_0 e^{-\alpha(\omega)s}$$

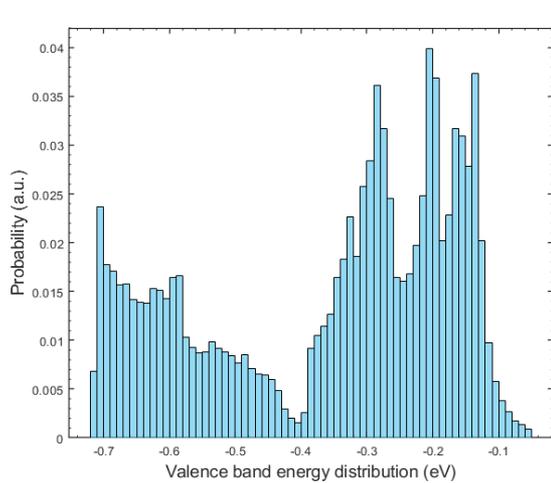
- Absorption coefficient  $\alpha(\omega)$  depends on the wavelength.
- The absorption coefficient  $\alpha(\omega)$  - 0.0577 was obtained by interpolating the figure on the left side [03].
- In this simulation, I consider 15 nm thickness.
- Assumption 1 – The absorption coefficient is constant for all photon energies.
- Far from the threshold region, the absorption should not vary significantly.

# Initial parameters for an electron

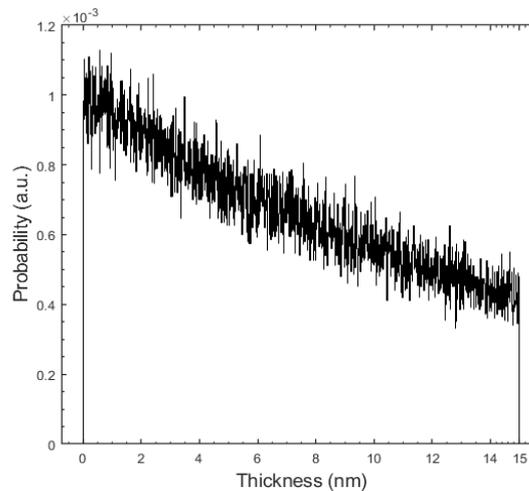
- Assumption 2 - Each photon (no photon= $2 \times 10^5$ ) emits an electron from the valence band.
- The Density of states (DOS) of the valence band is used to select the number of electrons.
- Conduction band minimum set as the energy zero point.
- This simulation uses the experimental band gap energy (3.3 eV) value.
- Conduction band energy = VB energy + Photon energy - Band gap.
- The position of an electron is calculated using the Monte Carlo simulation.
- $F(s) = \alpha(\omega)e^{-\alpha(\omega)s}$  is the distribution of the position of excited electrons.
- The initial direction was selected using the Monte Carlo simulation assuming all the directions are isotropic.

# Distributions for initial variables

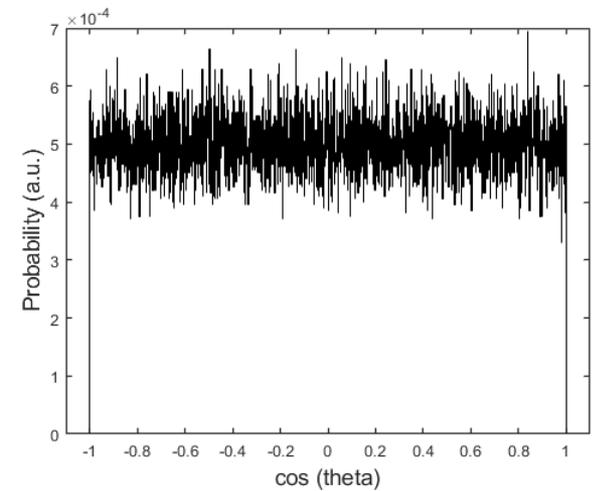
## Valence Band Energy, Longitudinal Position, and $\cos(\theta)$



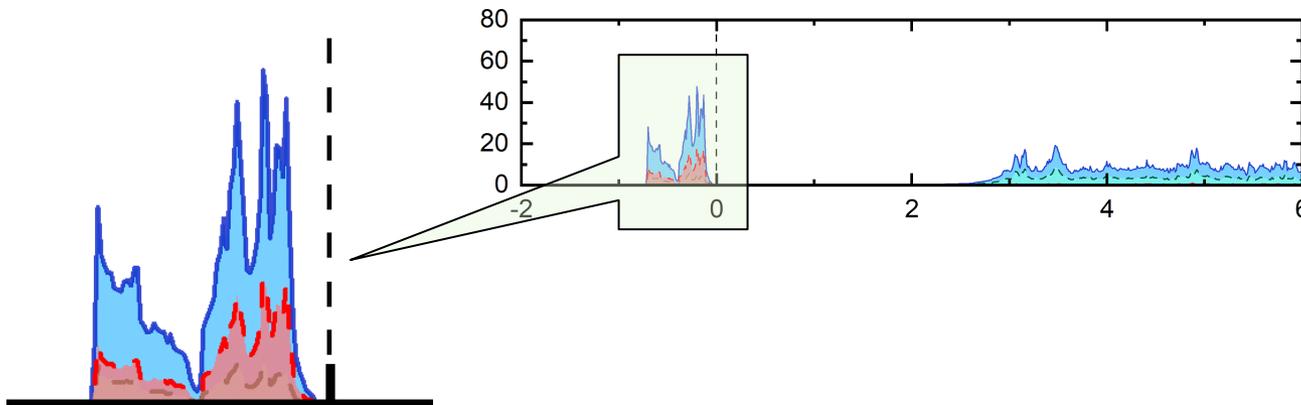
Valence band energy distribution. The bin size is 0.01 eV.



Electron position distribution. The bin size is 0.01 nm.



Cos( $\theta$ ) distribution. The bin size is  $1 \times 10^{-4}$ .



# Phonon Scattering – Cs<sub>2</sub>Te

## Inter valley scattering

- If photon energy is greater than 2\*band gap ( $E_g$ ) the electron-electron scattering dominates.
- For photon energies less than  $2E_g$  e-e scattering has a very low probability and electron energy reduces due to electron-phonon scattering.
- For simplicity, only optical phonon scattering and inter valley phonon scattering considered.
- When electrons' energy is high enough to scatter into other valleys, inter valley scattering dominates.
- Inter valley scattering rate

$$\lambda_{i\pm}(E) = \frac{D_i^2 m^{*3/2} (N_q + \frac{1}{2} \mp \frac{1}{2})}{\sqrt{2\pi} \hbar^2 \rho E_{ph}} (E \pm E_{ph})^{1/2}$$

+/- - absorption and emission

$E_{ph}$  – phonon energy

$D_i$  – deformation potential  $1 \times 10^9$  eV/cm

$\rho$  – density of material

# Phonon scattering rates

## Polar optical phonons

- Electrons lie in one band; polar optical phonon scattering is the dominant process.
- Polar optical phonon scattering rate

$$\lambda_{0\pm}(E) = \frac{e^2 m^{*1/2} E_{ph} (N_q + \frac{1}{2} \mp \frac{1}{2})}{4\sqrt{2}\pi\hbar^2 \epsilon_0 \epsilon_p E^{1/2}} \ln \left| \frac{(E \pm E_{ph})^{1/2} + E^{1/2}}{(E \pm E_{ph})^{1/2} - E^{1/2}} \right|$$

$$\epsilon_p = \frac{1}{1/\epsilon_\infty - 1/\epsilon_s}$$

- The Occupation number of the phonon follows the Bose-Einstein statistics,

$$N_q = \frac{1}{\exp(E_{ph}/k_B T) - 1}$$

+/- - absorption and emission

$E_{ph}$  - phonon energy

$\epsilon_\infty, \epsilon_s$  - high frequency and static dielectric constant

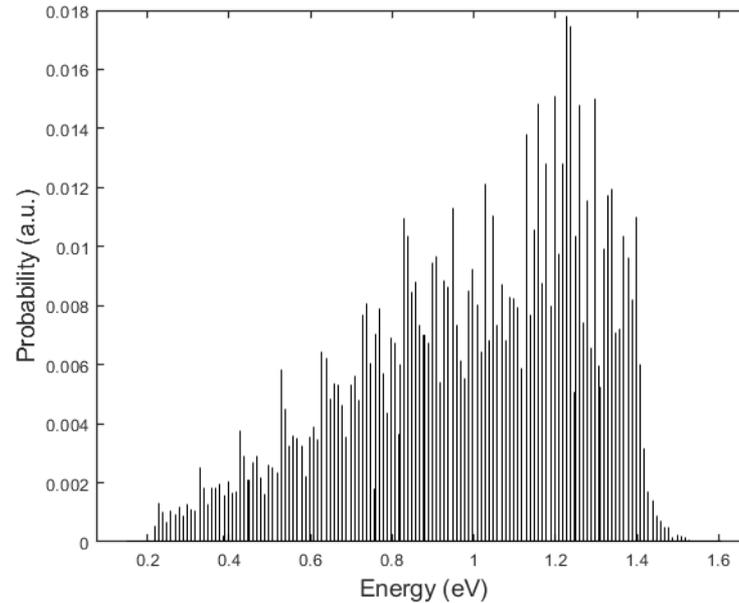
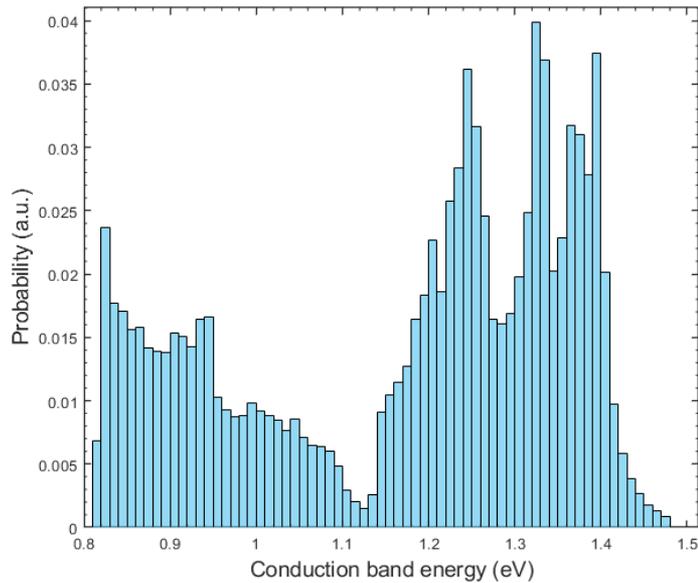
# Phonon scattering cont.

- Scattering rate  $\lambda(E)=\lambda_{0-} + \lambda_{0+}$ , for electrons with energy lower than the minimum of the second lowest band.
  - $\lambda_{0-}/\lambda$ , is the possibility of emitting an electron and energy loss  $E_{ph}$ .
  - $\lambda_{0+}/\lambda$ , is the possibility of absorbing an electron and energy absorption  $E_{ph}$ .
- Scattering rate  $\lambda(E)=\lambda_{0-} + \lambda_{0+} + \lambda_{i-} + \lambda_{i+}$ , for electrons with higher energy.
  - $(\lambda_{0-}+\lambda_{i-})/\lambda$ , is the possibility of emitting an electron and energy loss  $E_{ph}$ .
  - $(\lambda_{0+}+\lambda_{i+})/\lambda$ , is the possibility of absorbing an electron and energy absorption  $E_{ph}$ .
- The probability for an electron to travel a distance  $d$  without suffering a scattering event is  $P(\lambda) = \exp\left(-\frac{d}{\lambda}\right)$ , where  $\lambda$  is the electron's mean free path.
- After scattering, the change of direction is not isotropic.
- The polar angle  $\theta$  between the original and the new trajectory and the azimuthal angle  $\varphi$  will follow the distributions,

$$g_1(\theta) \propto \frac{\sin \theta}{E+(E \pm E_{ph})-2 \sqrt{(E(E \pm E_{ph}) \cos \theta)}},$$
$$g_2(\varphi) = \frac{1}{2\pi}.$$

# Energy Distribution

Photon energy = 4.83 eV



The left side picture represents the energy distribution in the conduction band before scattering. The right-side figure represents the energy distribution after scattering.

# Transmission probability

$$T(E, s, x, \xi, E_a) = D((E - \Delta E)x^2 + E_b, \xi, E_a)$$

$$D(E, \xi, E_a) = \frac{2}{1 + \frac{(H(E) + E)}{2\sqrt{EH(E)}} [e^{\theta(E)} - \frac{1}{4}(1 - e^{-\theta(E)})]}$$

$$\theta(E) = \begin{cases} 0 & E > E_a \\ \frac{2}{\hbar e \xi} \sqrt{2m^*(E_a - E)^3} & E \leq E_a \end{cases}$$

$$H(E) = \sqrt{(E - E_a)^2 + (f_0^2 \hbar^2 (e\xi)^2 / 2m^*)^{\frac{2}{3}}}$$

$f_0$ -dimensionless number 0.51697

$\xi$ - electric field

$\alpha(\omega)$ - absorption coefficient

$\Delta E$  – energy loss

# Quantum Efficiency

- When the electrons approach the surface, they will traverse the band bending region and obtain extra  $E_b$  in the longitudinal direction and the Schottky reduction  $E_{sch}$ .
- The quantum efficiency is calculated using the number of scattered electrons and the no of photons.
- Reflection, absorption, and transmission possibilities are considered to calculate the number of electrons.

$$QE = \frac{(1 - R) * (1 - \exp(-\alpha T)) * \text{scattered and emitted electrons}}{\text{No of photons absorbed}}$$

# Thermal Emittance

- The transverse momentum conservation law at the surface,

$$P_{trans}^{in} = P_{trans}^{out}$$

$$P^{out} = \sqrt{(2m_0(E + E_b + E_{sch}))}$$

$$P_{trans}^{out} = \sqrt{(2m_0(E + E_b + E_{sch}))} \sin\theta \cos\phi$$

$$E_{sch} \text{ (eV)} = 0.038 \sqrt{E \text{ (MV/m)}}$$

$$P^{out} > P_{trans}^{out}$$

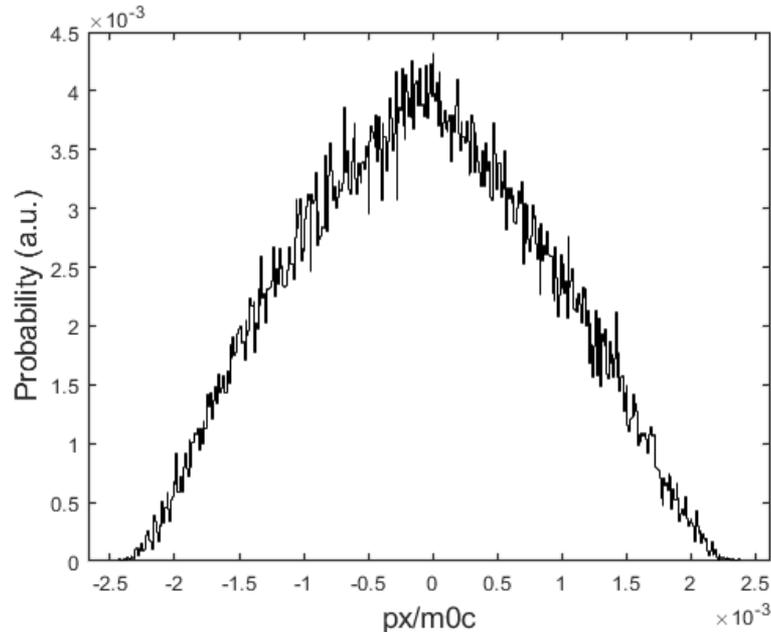
- The normalized transverse rms emittance may be deduced by measuring the rms beam divergence at the cathode for a given beam spot size.
- The normalized transverse rms emittance is defined as

$$\epsilon_{n,rms} = \frac{1}{m_0 c} \sqrt{\sigma^2(x) \sigma^2(p_x) - \sigma^2(xp_x)}$$

- The correlation term  $\sigma^2(xp_x)$  vanishes at the source since the quantities  $x$  and  $p_x$  are uncorrelated.

$$\epsilon_{n,rms} = \frac{1}{m_0 c} p_{x,rms} \times x_{rms}$$

# Normalized Transverse Momentum Distribution



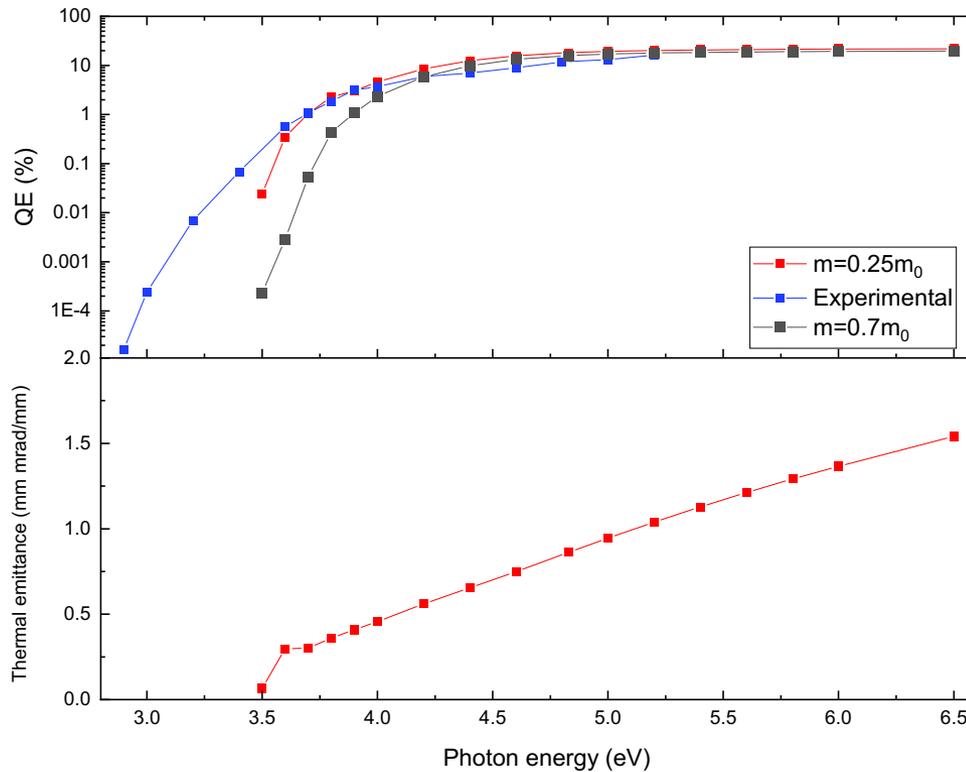
The probability distribution for the normalized transverse momentum at the cathode for photo-emitted electrons. A bin of  $1 \times 10^{-5}$  is used for the normalized transverse momentum. Laser spot size 1.5 mm.

# Constants used in this simulation

|   |                        |
|---|------------------------|
| <b>Band gap <math>E_g</math></b>                                  | 3.3 eV                 |
| <b>Electron affinity <math>E_a</math></b>                         | 0.25 eV                |
| <b>Band bending energy <math>E_b</math></b>                       | 0.05 eV                |
| <b>Effective mass <math>m^*</math></b>                            | 0.7 $m_0$              |
| <b>Reflectivity <math>R</math></b>                                | 20 %                   |
| <b>Thickness <math>l</math></b>                                   | 15 nm                  |
| <b>Phonon energy <math>E_{ph}</math></b>                          | 0.04 eV                |
| <b>Static dielectric constant <math>\epsilon_\infty</math></b>    | 3                      |
| <b>High frequency dielectric constant <math>\epsilon_s</math></b> | 5.76                   |
| <b>Density of material <math>\rho</math></b>                      | 3.99 gcm <sup>-3</sup> |

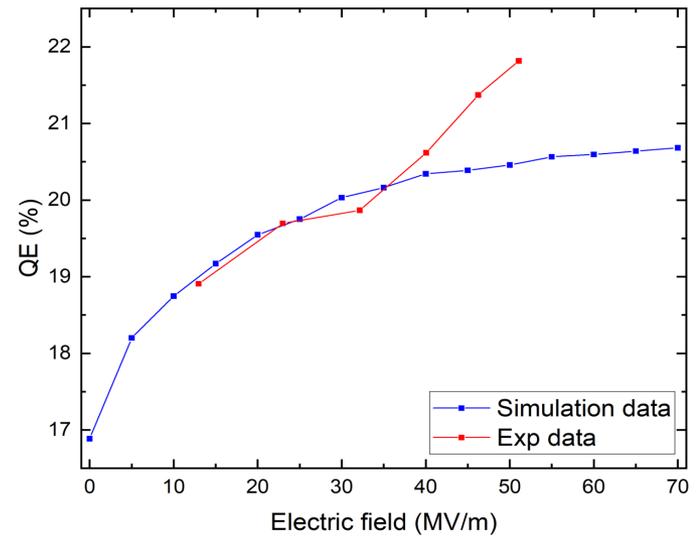
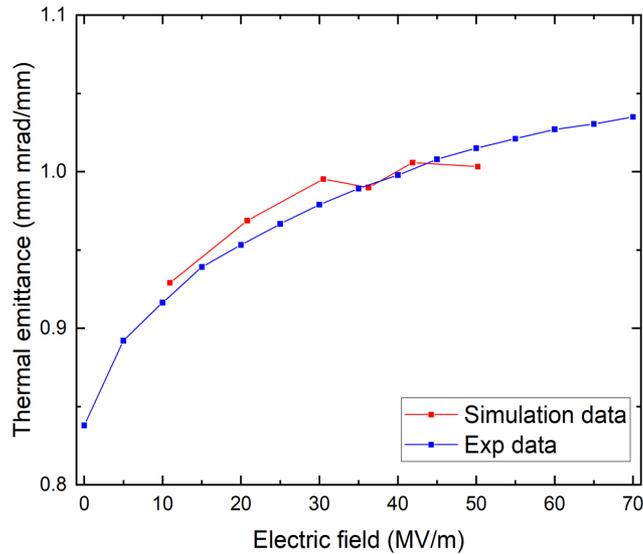
# Quantum Efficiency and Thermal Emittance

Electric Field= 0 MVm<sup>-1</sup>



# Thermal emittance and QE at 15 nm

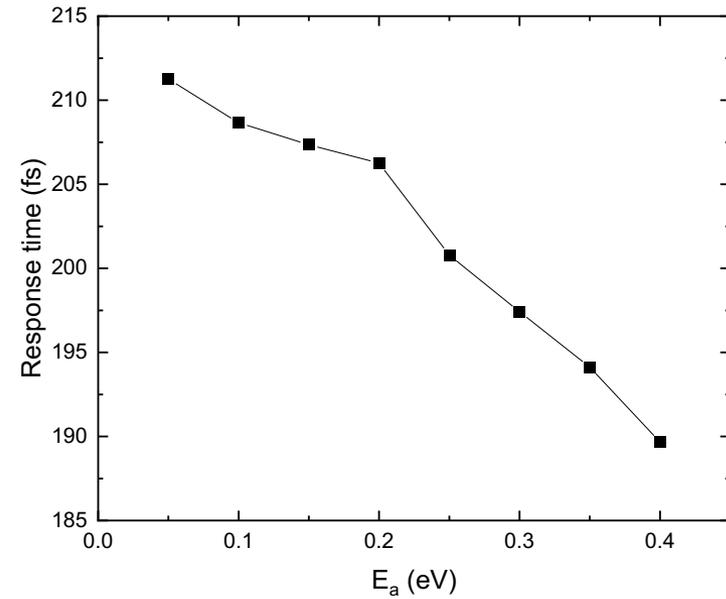
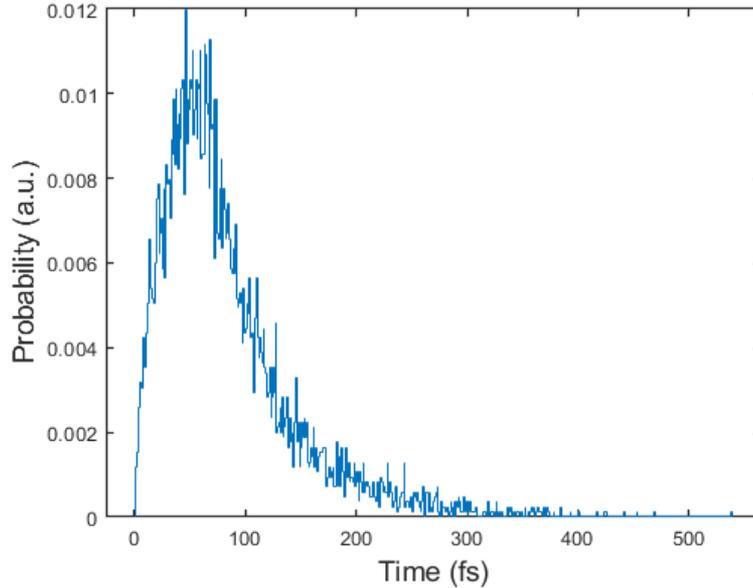
Photon Energy = 4.83 eV



Comparison between the simulation results, and the experimental data in Thermal emittance and QE for Cs<sub>2</sub>Te at 4.83 eV. The thickness of the photocathode is 15 nm.

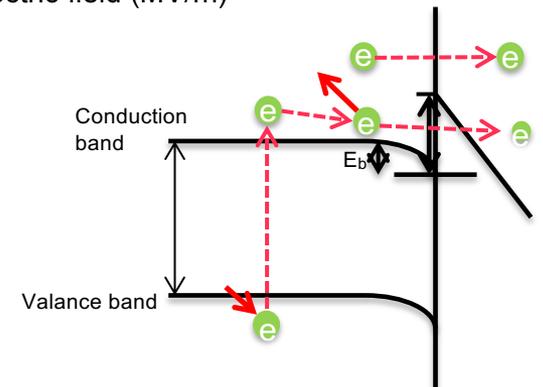
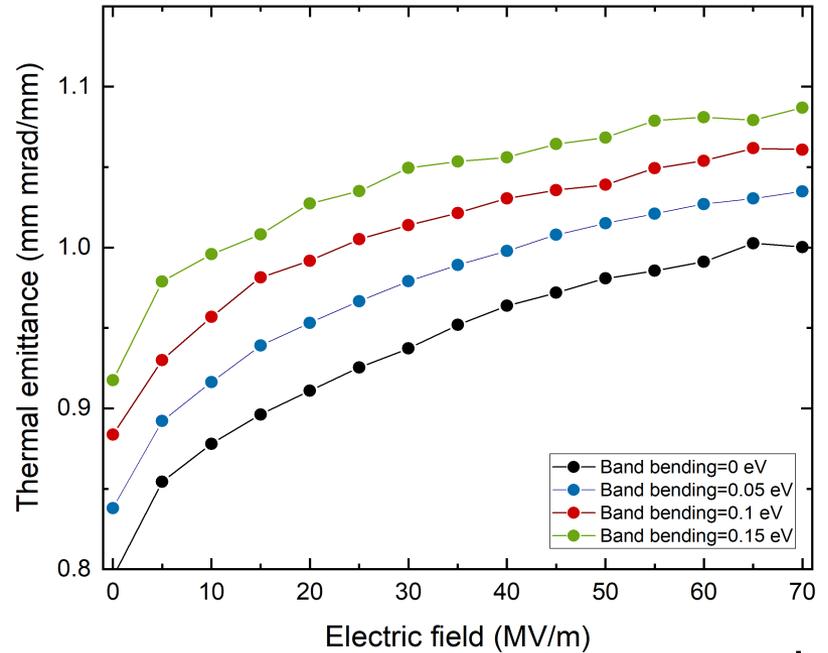
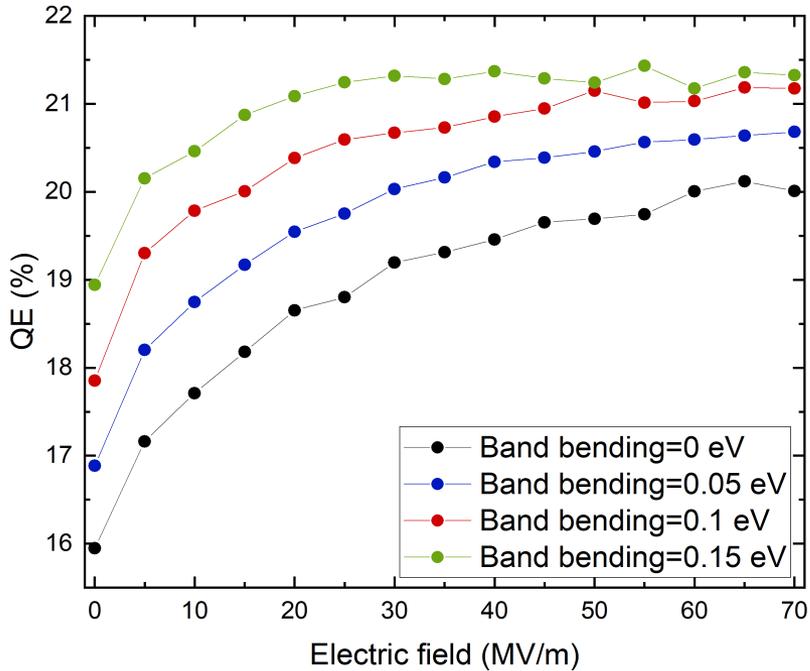
# Response time- Cs<sub>2</sub>Te

Electric Field = 20 MVm<sup>-1</sup> and Photon Energy= 4.83 eV



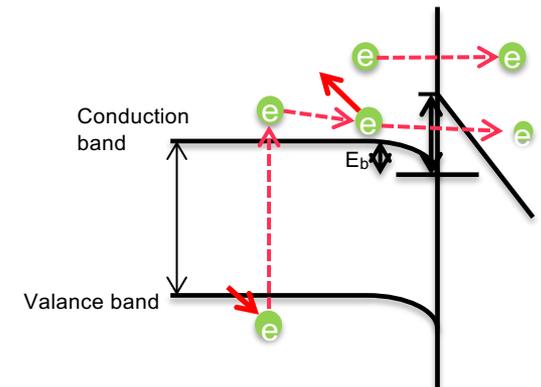
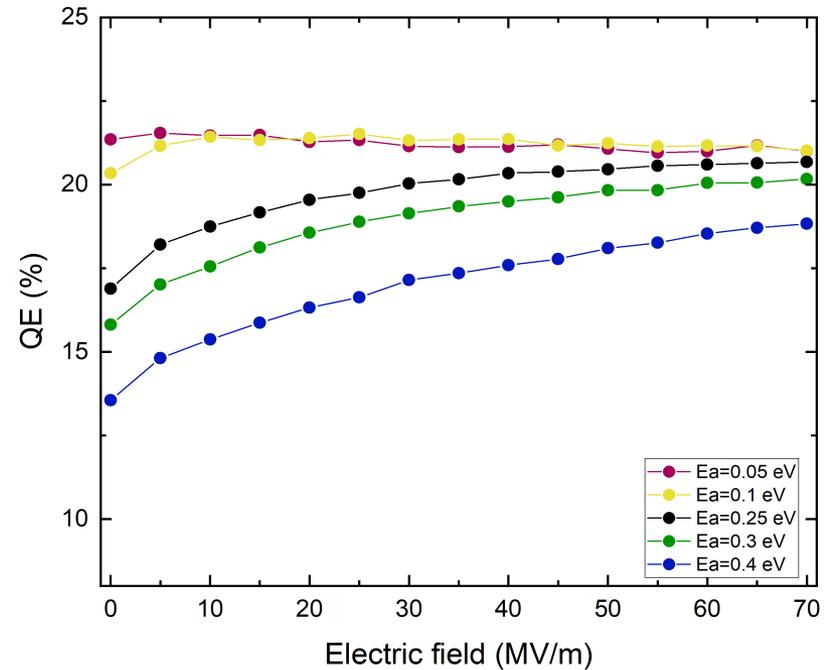
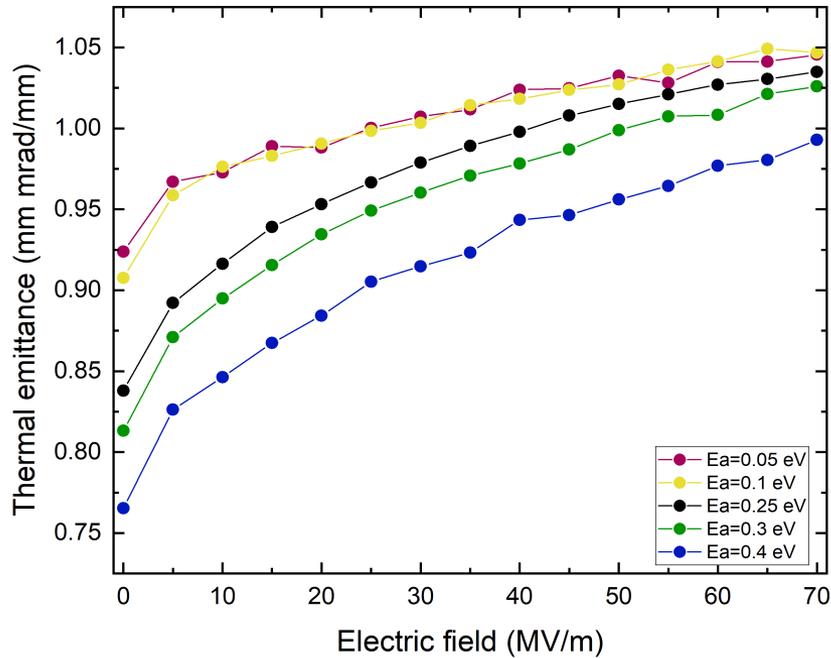
# Band Bending Effect

Photon Energy = 4.83 eV



# Electron affinity effect

Photon Energy = 4.83 eV



# Summary

- Monte Carlo Simulation was used to calculate quantum efficiency and thermal emittance
- The density functional theory calculated DOS distribution incorporated in the simulation.
- The direction change after each scattering event considered in the simulation.
- e- ph scattering is considered and mainly focused on polar optical phonon scattering and intervalley phonon scattering.
- Calculated thermal emittance values and quantum efficiency values agree with the experimental values.
- The response time is 200.7 fs at a  $20 \text{ MVm}^{-1}$  electric field and 4.83 eV photon energy.

# References

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# Thank you

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